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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/006,269	12/04/2001	Shui-Hung Chen	67,200-537	2058
759	90 06/17/2002			
TUNG & ASSOCIATES Suite 120 838 W. Long Lake Road			EXAMINER	
			FARAHANI, DANA	
Bloomfield Hills	s, MI 48302		ART UNIT	KAMINER HANI, DANA PAPER NUMBER
			2814	
			DATE MAILED: 06/17/2002	

Please find below and/or attached an Office communication concerning this application or proceeding.

			9h			
	Application No.	Applicant(s)				
	10/006,269	CHEN ET AL.				
Office Action Summary	Examiner	Art Unit				
	Dana Farahani	2814				
The MAILING DATE of this communication Period for Reply	n appears on the cover sh	eet with the correspondence address				
A SHORTENED STATUTORY PERIOD FOR R THE MAILING DATE OF THIS COMMUNICATI - Extensions of time may be available under the provisions of 37 C after SIX (6) MONTHS from the mailing date of this communicatic - If the period for reply specified above is less than thirty (30) days, - If NO period for reply is specified above, the maximum statutory p - Failure to reply within the set or extended period for reply will, by - Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b). Status	ON. FR 1.136(a). In no event, however, on. a reply within the statutory minimum period will apply and will expire SIX (statute, cause the application to become statute.	may a reply be timely filed of thirty (30) days will be considered timely. NONTHS from the mailing date of this communication. The ABANDONED (35 U.S.C. § 133).				
1) Responsive to communication(s) filed or	04 <u>December 2001</u> .					
2a) ☐ This action is FINAL . 2b) ⊠	This action is non-final.					
closed in accordance with the practice u	allowance except for formander <i>Ex parte Quayle</i> , 193	al matters, prosecution as to the merits is 85 C.D. 11, 453 O.G. 213.				
Disposition of Claims	action					
4) Claim(s) 1-39 is/are pending in the application of the application		n				
4a) Of the above claim(s) is/are wit	Ingrawn from consideratio					
5) Claim(s) is/are allowed.						
· · · · · · · · · · · · · · · · · · ·	6)⊠ Claim(s) <u>1-39</u> is/are rejected.					
7) Claim(s) is/are objected to.	and/ar alastian requireme	•				
8) Claim(s) are subject to restriction a Application Papers	and/or election requiremen	it.				
9) The specification is objected to by the Exa	aminer.					
10)☐ The drawing(s) filed on is/are: a)☐		o by the Examiner.				
Applicant may not request that any objection						
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.						
If approved, corrected drawings are required	d in reply to this Office action					
12) ☐ The oath or declaration is objected to by the	he Examiner.					
Priority under 35 U.S.C. §§ 119 and 120						
13) Acknowledgment is made of a claim for for	oreign priority under 35 U	S.C. § 119(a)-(d) or (f).				
a) ☐ All b) ☐ Some * c) ☐ None of:						
1. Certified copies of the priority docu	ıments have been receive	d.				
2. Certified copies of the priority documents have been received in Application No						
 3. Copies of the certified copies of the application from the Internation * See the attached detailed Office action for 	nal Bureau (PCT Rule 17.2	?(a)).				
14) Acknowledgment is made of a claim for do).			
a) The translation of the foreign languages	ge provisional application	has been received.				
Attachment(s)	, ,					
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-9-9-3) Information Disclosure Statement(s) (PTO-1449) Paper I	48) 5) 🔲 No	erview Summary (PTO-413) Paper No(s) tice of Informal Patent Application (PTO-152) ner:				

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

The changes made to 35 U.S.C. 102(e) by the American Inventors Protection Act of 1999 (AIPA) do not apply to the examination of this application as the application being examined was not (1) filed on or after November 29, 2000, or (2) voluntarily published under 35 U.S.C. 122(b). Therefore, this application is examined under 35 U.S.C. 102(e) prior to the amendment by the AIPA (pre-AIPA 35 U.S.C. 102(e)).

2. Claims 1-18, 21-23, and 26-39 are rejected under 35 U.S.C. 102(e) as being anticipated by Yu (U.S. 6,353,237).

Regarding claims 1-5, Yu discloses in figure 6 an SCR voltage transient protection device comprising a pair of complementary bipolar transistors, 40 and 41, each having a respective base, emitter and collector, the SCR fabricated such that a reach-through effect across the base of at least one of the complementary bipolar transistors causes triggering of the device.

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Regarding claims 7-18, 21-23, and 26-39, Yu discloses in figure 4, a silicon controlled rectifier device comprising: a first lightly doped region 31 having a first conductivity type formed in a second lightly doped region 30 having a second conductivity type; a first heavily doped region 34 having the first conductivity type formed in the second lightly doped region; a second heavily doped region 33 having the second conductivity type formed in the first lightly doped region; the second heavily doped region, the first lightly doped region and the second lightly doped region forming an emitter, a base and a collector, respectively, of a first transistor; the first heavily doped region, the second lightly doped region and the first lightly doped region forming an emitter, a base and a collector, respectively, of a second transistor; an avalanche junction formed at the interface of the first and second lightly doped regions having an avalanche junction breakdown voltage; and wherein one of the first and second transistors is characterized by attaining a reach-through voltage prior to the avalanche junction attaining the avalanche junction breakdown voltage.

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which the subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 19, 20, 24, and 25 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yu.

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Regarding claims 19, 20, 24, and 25, Yu discloses the claimed invention except expressly disclosing the values in the claims. It would have been obvious to one of ordinary skill in the art at the time the invention was made to include these values since it has been held that discovering an optimum value of a result effective variable involves only routine skill in the art.

Product-by-Process Limitations

While not objectionable, the Office reminds Applicant that "product by process" limitations in claims drawn to structure are directed to the product, per se, no matter how actually made. *In re Hirao*, 190 USPQ 15 at 17 (footnote 3) which make it clear that it is the patentability of the final product per se which must be determined in a "product by process" claim, and not the patentability of the process. Thus, no patentable weight will be given to those process steps which do not add structural limitations to he final product.

For example in claim 6, the "CMOS compatible process" does not offer any structural limitation to the final product, thus given no patentable weight.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dana Farahani whose telephone number is (703)305-1914. The examiner can normally be reached on M-F 8:00AM - 5:00PM.

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supervisor, Olik Chaudhuri can be reached on (703)306-2794. The fax phone numbers for the organization where this application or proceeding is assigned are (703)872-9318 for regular communications and (703)872-9319 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)308-0956.

Dana Farahani June 12, 2002

> OLIK CHAUDHURI SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800

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